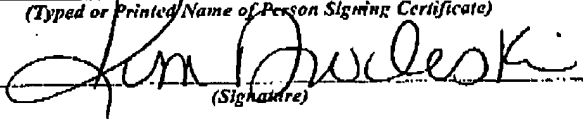


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**JUN 13 2005**

<b>CERTIFICATE OF TRANSMISSION BY FACSIMILE (37 CFR 1.8)</b>			Docket No. <b>BUR920040060US1</b>
Applicant(s): <b>Barkyoumb et al.</b>			
Application No. <b>10/709,562</b>	Filing Date <b>5/13/2004</b>	Examiner <b>Huynh, Yeanhu B.</b>	Group Art Unit <b>2813</b>
Invention: <b>METAL SEED LAYER DEPOSITION</b>			
<p>I hereby certify that this _____ <b>Restriction Election (2 pages)</b> _____  <small>(Identify type of correspondence)</small></p> <p>is being facsimile transmitted to the United States Patent and Trademark Office (Fax. No. <b>703-872-9306</b>)</p> <p>on <u><del>6/10/2005</del> 6/13/05</u>  <small>(Date)</small></p> <div style="text-align: right; margin-top: 100px;"> <p><b>Kim Dwileski</b>  <small>(Typed or Printed Name of Person Signing Certificate)</small></p>   <small>(Signature)</small> </div>			
<p><b>Note: Each paper must have its own certificate of mailing.</b></p>			

DOCKET NO.: BUR920040060US1

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Barkyoub *et al.*

Examiner: Huynh, Yennhu B.

Serial No.: 10/709,562

Art Unit: 2813

Filed: 5/13/2004

For: **METAL SEED LAYER DEPOSITION**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**RESTRICTION ELECTION**

In response to the Restriction Requirement dated May 17, 2005, Applicants hereby provisionally elect Group I, claims 1-25, drawn to a method for forming a seed layer, classified in Class 438, subclass 597. This election is made with traverse, and Applicants hereby reserve the right to file a divisional application in connection with unelected claim 26, drawn to a semiconductor structure.

With regard to the Restriction Requirement, Applicants respectfully submit that the subject matter of all claims 1-26 is sufficiently related that a thorough search for the subject matter of any one group of claims would encompass a search for the subject matter of the remaining claims. Thus, Applicants respectfully submit that the search and the examination of the entire application could be made without serious burden. See MPEP § 803, in which it is stated that "if the search and examination of the entire application can be made without serious burden, the Examiner must examine it on the merits." Applicants respectfully submit that this policy


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should apply in the present application in order to avoid unnecessary delay and expense to Applicants and duplicative examination by the Patent Office.

Should the Examiner require or request anything further from Applicants prior to examination, the Examiner is requested to contact Applicants' undersigned representative at the telephone number below. Otherwise, Applicants request early and favorable examination on the merits. The Director is hereby authorized to charge and/or credit Deposit Account No. 09-0456.

Date: June 10, 2005

  
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